

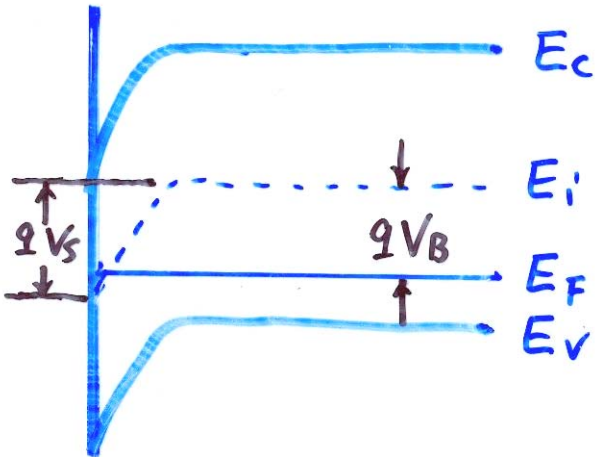
10.2 表面电场效应₂

10.2.1 空间电荷层

表面势 V_s —空间电荷层两端的电势差，表面比内部高为正

$$E_c(x) = E_{c0} - qV(x)$$

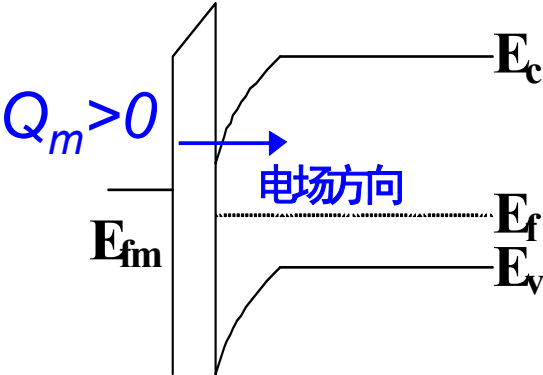
$$V_s = -\frac{E_{is} - E_{ib}}{q}$$



Q_m	V_s	Q_s	能带弯曲
+	+	-	↓
-	-	+	↑

助记例子:

Q_m	V_s	Q_s	能带弯曲
+	+	-	↓

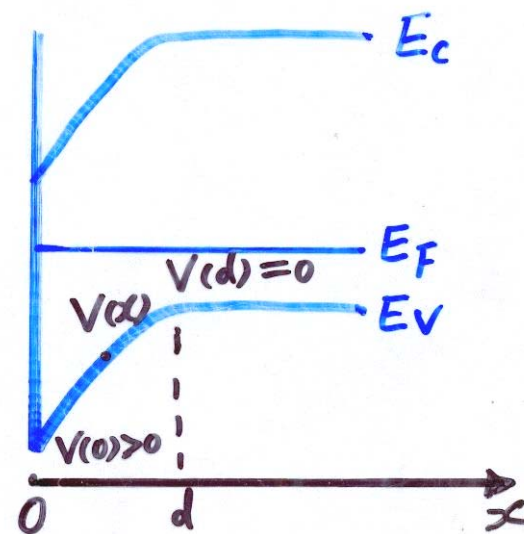


电力线从正电荷出发终止于负电荷，电势沿电力线方向减小

10.2 表面电场效应₃

10.2.2 空间电荷层中的泊松方程

- 假设
- 1° 半导体表面是个无限大的面，其线度 \gg 空间电荷层厚度 \rightarrow 一维近似， (ρ, E, V) 不依赖 y, z
 - 2° 半导体厚度 \gg 空间电荷层厚度 \rightarrow 半导体体内电中性
 - 3° 半导体均匀掺杂
 - 4° 非简并统计适用于空间电荷层
 - 5° 不考虑量子效应



10.2 表面电场效应₃

10.2.2 空间电荷层中的泊松方程

例子：一维p型半导体

$$\frac{d^2V(x)}{dx^2} = -\frac{\rho(x)}{\epsilon_s} \quad \text{泊松方程}$$

$$\rho(x) = q(N_D^+ - N_A^- + p_p - n_p)$$

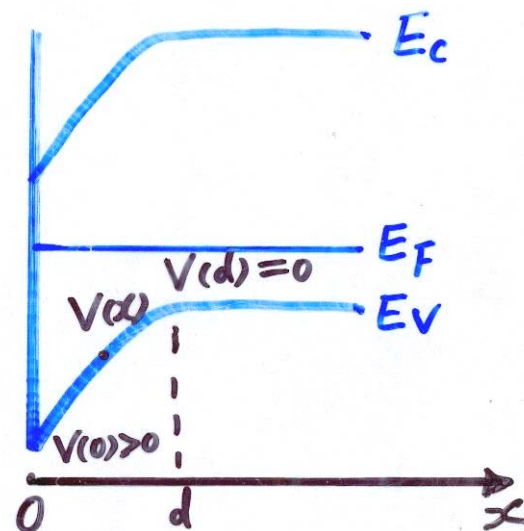
$$n_p = n_{p0} \exp(qV/kT)$$

$$p_p = p_{p0} \exp(-qV/kT)$$

} 玻尔兹曼统计

已知 $x \rightarrow +\infty$ 时 $\rho(x) = 0 \rightarrow N_D^+ - N_A^- = n_{p0} - p_{p0}$

$$\frac{d^2V(x)}{dx^2} = \frac{dV}{dx} \cdot \frac{d\left(\frac{dV}{dx}\right)}{dV} = -\frac{q}{\epsilon_s} \{p_{p0}[\exp(-qV/kT) - 1] - n_{p0}[\exp(qV/kT) - 1]\}$$



10.2 表面电场效应₄

10.2.2 空间电荷层中的泊松方程

例子：一维p型半导体

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$$\frac{d^2V(x)}{dx^2} = \frac{dV}{dx} \cdot \frac{d\left(\frac{dV}{dx}\right)}{dV} = -\frac{q}{\epsilon_s} \left\{ p_{p0} [\exp(-qV/kT) - 1] - n_{p0} [\exp(qV/kT) - 1] \right\}$$

↓ 两边乘以dV

$$\frac{dV}{dx} d\left(\frac{dV}{dx}\right) = -\frac{q}{\epsilon_s} \left\{ p_{p0} [\exp(-qV/kT) - 1] - n_{p0} [\exp(qV/kT) - 1] \right\} dV$$

↓ 从空间电荷层内边界积分到表面

$$\int_0^{\frac{dV}{dx}} \frac{dV}{dx} d\left(\frac{dV}{dx}\right) = \int_0^V \left(-\frac{q}{\epsilon_s} \right) \left\{ p_{p0} [\exp(-qV/kT) - 1] - n_{p0} [\exp(qV/kT) - 1] \right\} dV$$

$$\downarrow E = -\frac{dV(x)}{dx}$$

$$E^2(x) = \left(\frac{2kT}{q} \right)^2 \left(\frac{q^2 p_{p0}}{2\epsilon_s kT} \right) \left\{ \left[\exp\left(-\frac{qV}{kT} \right) + \frac{qV}{kT} - 1 \right] + \frac{n_{p0}}{p_{p0}} \left[\exp\left(\frac{qV}{kT} \right) - \frac{qV}{kT} - 1 \right] \right\}$$

10.2 表面电场效应₅

10.2.2 空间电荷层中的泊松方程

例子：一维p型半导体

$$E^2(x) = \left(\frac{2kT}{q}\right)^2 \left(\frac{q^2 p_{p0}}{2\varepsilon_s kT}\right) \left\{ \left[\exp\left(-\frac{qV}{kT}\right) + \frac{qV}{kT} - 1 \right] + \frac{n_{p0}}{p_{p0}} \left[\exp\left(\frac{qV}{kT}\right) - \frac{qV}{kT} - 1 \right] \right\}$$

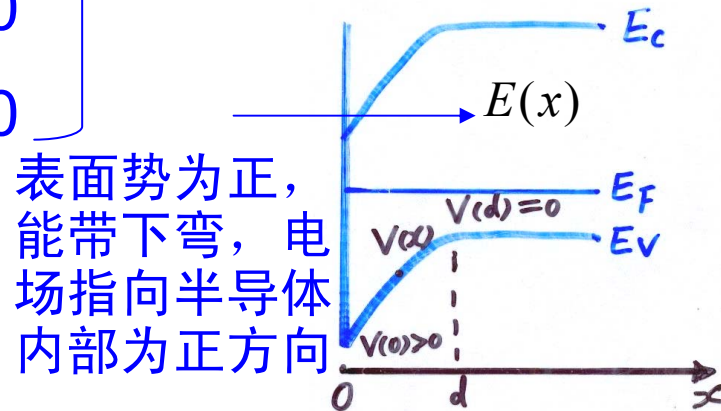
$$E(x) = \pm \frac{2kT}{qL_D} F\left(\frac{qV(x)}{kT}, \frac{n_{p0}}{p_{p0}}\right) \begin{cases} \text{“+”} : V > 0 \\ \text{“-”} : V < 0 \end{cases}$$

$$L_D = \left(\frac{2\varepsilon_s kT}{q^2 p_{p0}}\right)^{1/2}$$

德拜长度
(p型半导体)

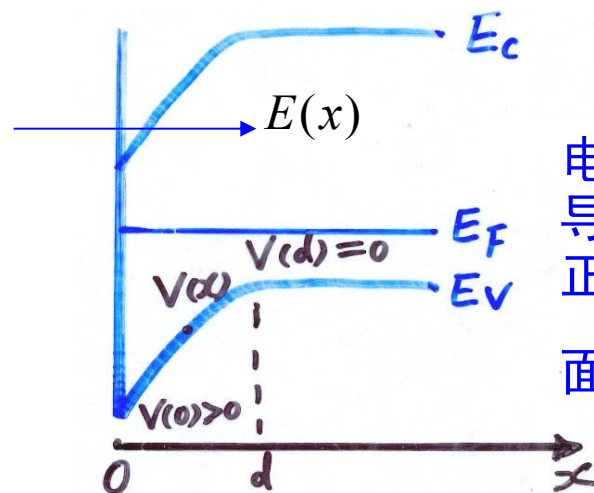
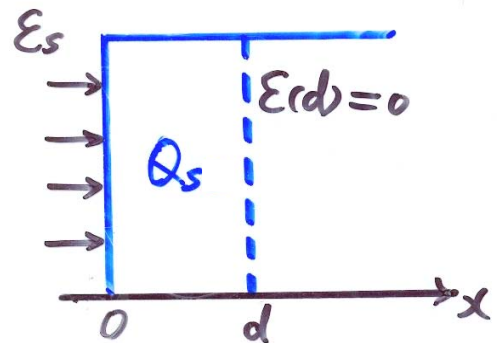
$$F\left(\frac{qV}{kT}, \frac{n_{p0}}{p_{p0}}\right) = \left\{ \left[\exp\left(-\frac{qV}{kT}\right) + \frac{qV}{kT} - 1 \right] + \frac{n_{p0}}{p_{p0}} \left[\exp\left(\frac{qV}{kT}\right) - \frac{qV}{kT} - 1 \right] \right\}^{1/2}$$

F 函数，无量纲数



10.2 表面电场效应₆

10.2.3 半导体表面电场、电势和电容



电场指向半
导体内部为
正方向

面电荷密度

$$E(x) = \pm \frac{2kT}{qL_D} F\left(\frac{qV(x)}{kT}, \frac{n_{p0}}{p_{p0}}\right)$$

$$x=0 \quad V(0) = V_s$$

$$E_s = \pm \frac{2kT}{qL_D} F\left(\frac{qV_s}{kT}, \frac{n_{p0}}{p_{p0}}\right)$$

$$Q_s = -\epsilon_s E_s = \mp \frac{2\epsilon_s kT}{qL_D} F\left(\frac{qV_s}{kT}, \frac{n_{p0}}{p_{p0}}\right)$$

$$C_s = \left| \frac{dQ_s}{dV_s} \right| = \frac{\epsilon_s}{L_D} \left\{ \left[-\exp\left(-\frac{qV_s}{kT}\right) + 1 \right] + \frac{n_{p0}}{p_{p0}} \left[\exp\left(\frac{qV_s}{kT}\right) - 1 \right] \right\} / F\left(\frac{qV_s}{kT}, \frac{n_{p0}}{p_{p0}}\right)$$

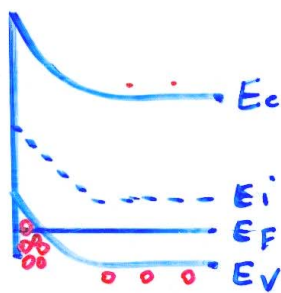
10.2 表面电场效应₇

10.2.4 半导体表面层的五种基本状态

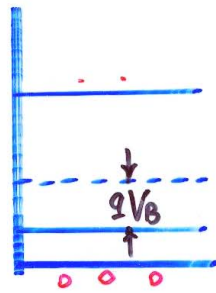
1° 多子堆积（积累）状态 $Q_s \propto \exp(-qV_s/2kT) \quad V_s < 0$

2° 平带状态 $C_{FBS} = \lim_{V_s \rightarrow 0} \frac{dQ_s}{dV_s} = \frac{\sqrt{2}\epsilon_s}{L_D} \left(1 + \frac{n_{p0}}{p_{p0}}\right)^{1/2} \approx \frac{\sqrt{2}\epsilon_s}{L_D} \quad V_s = 0$

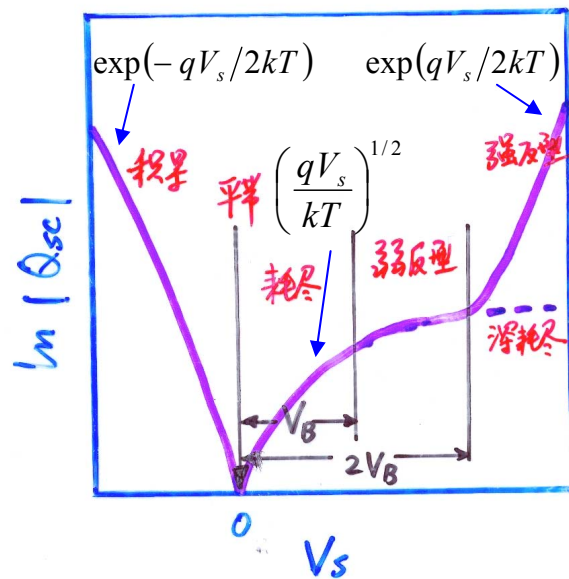
$$Q_s \propto E_s \propto F(V_s) = \left\{ \left[\exp\left(-\frac{qV_s}{kT}\right) + \frac{qV_s}{kT} - 1 \right] + \frac{n_{p0}}{p_{p0}} \left[\exp\left(\frac{qV_s}{kT}\right) - \frac{qV_s}{kT} - 1 \right] \right\}^{1/2}$$



积累

 $V_s < 0$ 

平带

 $V_s = 0$ 

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10.2.4 半导体表面层的五种基本状态

3° 耗尽状态 $V_B > V_S > 0$

$$F\left(\frac{qV_s}{kT}, \frac{n_{p0}}{p_{p0}}\right) = \left(\frac{qV_s}{kT}\right)^{1/2} Q_s = -\frac{2\epsilon_s kT}{qL_D} \left(\frac{qV_s}{kT}\right)^{1/2} L_D = \left(\frac{2\epsilon_s kT}{q^2 p_{p0}}\right)^{1/2}$$

另一种求解面电荷密度的途径—“耗尽层近似”

$$Q_s = -qN_A d \rightarrow E_s = \left| \frac{qN_A d}{\epsilon_s} \right|^{1/2}$$
$$Q_s = -qN_A \left(\frac{2\epsilon_s}{q} \frac{V_s}{N_A} \right)^{1/2} = -(2\epsilon_s q N_A V_s)^{1/2} \leftarrow d = \left(\frac{2\epsilon_s}{q} \frac{V_s}{N_A} \right)^{1/2}$$

